Special Issue

2nd Edition of Green Particle Technologies: Processes and Applications

Message from the Guest Editors

The aim of this Special Issue, "2nd Edition of Green Particle Technologies: Processes and Applications", is to present the most recent advancements in the development of such technologies. We invite novel contributions focused on, but not limited to, the following areas:

- Green processes in the synthesis, formation, and modification of particles and in particle handling and operations;
- The use of green materials in particle-related products;
- The application of particle technology in the production of green products;
- Processes in the treatment of waste and harmful particles;
- New characterization methods and techniques enabling the development of green particulate materials and products.

Guest Editors

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Deadline for manuscript submissions

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Message from the Editor-in-Chief

You are invited to contribute either a research article or a comprehensive review for consideration and publication in *Processes* (ISSN 2227-9717). *Processes* is published in open access format – research articles, reviews, and other content are released on the internet immediately after acceptance. The scientific community and the general public have unlimited, free access to the content. As an open access journal, *Processes* is supported by the authors and their institutes through the payment of article processing charges (APCs) for accepted papers. We would be pleased to welcome you as one of our authors.

Editor-in-Chief

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